# organic compounds

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## Tetrakis(4-tert-butylbenzyl)silane

### Lauren E. Burnham, Rulla M. Kachlan, Andy A. Thomas, Craig A. Ogle and Daniel S. Jones\*

Department of Chemistry, The University of North Carolina at Charlotte, 9201 University City Blvd., Charlotte, NC 28223, USA Correspondence e-mail: djones@uncc.edu

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Key indicators: single-crystal X-ray study; T = 295 K; mean  $\sigma$ (C–C) = 0.003 Å; *R* factor = 0.041; *wR* factor = 0.135; data-to-parameter ratio = 16.4.

The title compound,  $C_{44}H_{60}Si$ , was prepared as an internal standard for diffusion-ordered NMR spectroscopy. The Si atom lies on a special position with  $\overline{4}$  site symmetry.

### **Related literature**

For applications of the title compound in NMR spectroscopy, see: Li *et al.* (2009). For similar structures in the same space group, see: Liao *et al.* (2002); Laliberté *et al.* (2004). For a previously reported NMR standard, see: Monroe *et al.* (2010). For a description of the Cambridge Structural Database, see: Allen (2002).



### Experimental

*Crystal data* C<sub>44</sub>H<sub>60</sub>Si

 $M_r = 617.01$ 

Tetragonal,  $P4_2/n$  a = 17.394 (2) Å c = 6.3613 (6) Å V = 1924.7 (4) Å<sup>3</sup> Z = 2

### Data collection

Enraf–Nonius CAD-4 diffractometer 5204 measured reflections 1738 independent reflections 1056 reflections with  $I > 2\sigma(I)$ 

#### Refinement

 $R[F^2 > 2\sigma(F^2)] = 0.041$  $wR(F^2) = 0.135$ S = 1.021738 reflections Cu  $K\alpha$  radiation  $\mu = 0.72 \text{ mm}^{-1}$  T = 295 K $0.31 \times 0.15 \times 0.12 \text{ mm}$ 

R<sub>int</sub> = 0.036 3 standard reflections every 113 reflections intensity decay: 2%

106 parameters H-atom parameters constrained 
$$\begin{split} &\Delta \rho_{max} = 0.13 \text{ e } \text{\AA}^{-3} \\ &\Delta \rho_{min} = -0.11 \text{ e } \text{\AA}^{-3} \end{split}$$

Data collection: *CAD-4 EXPRESS* (Enraf–Nonius, 1994); cell refinement: *CAD-4 EXPRESS*; data reduction: *XCAD4* (Harms & Wocadlo, 1995); program(s) used to solve structure: *SHELXS97* (Sheldrick, 2008); program(s) used to refine structure: *SHELXL97* (Sheldrick, 2008); molecular graphics: *ORTEP-3 for Windows* (Farrugia, 1997) and *Mercury* (Macrae *et al.*, 2006); software used to prepare material for publication: *WinGX* (Farrugia, 1999).

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Supplementary data and figures for this paper are available from the IUCr electronic archives (Reference: SU2206).

#### References

- Allen, F. H. (2002). Acta Cryst. B58, 380-388.
- Enraf-Nonius (1994). CAD-4 EXPRESS. Enraf-Nonius, Delft, The Netherlands.
- Farrugia, L. J. (1997). J. Appl. Cryst. 30, 565.
- Farrugia, L. J. (1999). J. Appl. Cryst. 32, 837-838.
- Harms, K. & Wocadlo, S. (1995). XCAD4. University of Marburg, Germany.
- Laliberté, D., Maris, T. & Wuest, J. (2004). Can. J. Chem. 82, 386–398.
- Li, D., Kagan, G., Hopson, R. & Williard, P. G. (2009). J. Am. Chem. Soc. 131, 5627–5634.
- Liao, Y., Baskett, M., Lahti, P. & Palacio, F. (2002). Chem. Commun. pp. 252–253.
- Macrae, C. F., Edgington, P. R., McCabe, P., Pidcock, E., Shields, G. P., Taylor, R., Towler, M. & van de Streek, J. (2006). J. Appl. Cryst. **39**, 453–457.
- Monroe, T. B., Thomas, A. A., Jones, D. S. & Ogle, C. A. (2010). Acta Cryst. E66, 0132.
- Sheldrick, G. M. (2008). Acta Cryst. A64, 112-122.

# supporting information

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### Tetrakis(4-tert-butylbenzyl)silane

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### S1. Comment

The title compound was prepared as an internal standard for diffusion-ordered NMR spectroscopy. A recent paper on this subject (Li *et al.*, 2009) suggests an internal standard method for correlating diffusion coefficients with formula weights. The title compound was chosen because its shape in solution both approximates that of a spheroid and is similar to that of the species being studied. In addition, it neither reacts with the species under study nor gives interfering NMR signals.

The molecular structure of the title molecule is illustrated in Fig. 1. The molecule sits on a fourfold rotoinversion axis, with the Si atom located at the point of inversion and the four ligands arranged tetrahedrally around the Si atom. The crystal packing of the title compound, viewed along the c axis, is illustrated in Fig. 2.

The space group, P4<sub>2</sub>/n, is relatively rare, comprising fewer than 700 of the half-million-plus structures in the Cambridge Structural Database [Version 5.31; Allen, 2002]. Similar structures which crystallized in the same space group include tetrakis(4-*N*-*t*-Butyl-*N*-aminoxylphenyl)silane (Liao *et al.*, 2002) and tetrakis(4-(Ethoxycarbonylamino)phenyl)-silane bis(dioxane) clathrate (Laliberté *et al.*, 2004).

We have previously reported on the crystal structure of another NMR standard of smaller molecular weight, bis(2-naphthylmethyl)diphenylsilane (Monroe *et al.*, 2010).

### **S2. Experimental**

The synthesis of the title compound is descibed in Fig. 3. A dry, 250 ml Schlenk flask, equipped with a magnetic stirbar, was charged with 4-tertbutyltoluene (I) (7.13 g, 50 mmol), potassium *tert*-butoxide (6.72 g, 55 mmol), then purged with nitrogen. 100 ml of freshly distilled dry THF was added and the reaction was cooled to 195 K. *n*-BuLi (23.91 ml, 2.3*M*, 55 mmol) was then added dropwise. The Schlenk flask was then capped and kept at 233 K overnight. The solution was again cooled to 195 K and 2.09 ml (1.68 g, 10 mmol) of tetrachlorosilane was added dropwise. The reaction mixture was allowed to warm to room temperature and stirred for two hours. The mixture was then quenched with deionized water and extracted three times with petroleum ether. The combined organic layers were dried with magnesium sulfate, filtered, and evaporated. Bulb-to-bulb distillation gave a tan solid, which was recrystallized from petroleum ether to yield pure colorless crystals of tetrakis(4-*tert*-butylbenzyl)silane (II) (3.45 g, 56% recovery).

mp 407–409 K; <sup>1</sup>H NMR (Toluene-*d*<sub>8</sub>, 300 MHz): 1.27 (*s*)9H, 2.14 (*s*)2H, 6.85 (*d*)2H, 7.20 (*d*)2H. <sup>13</sup>C NMR (Toluene*d*<sub>8</sub>, 300 MHz): 31.66, 34.20, 20.71, 124.96, 128.75, 129.52, 147.13. GC/MS (70ev) m/z: 469.4, 57.1

### **S3. Refinement**

The H-atoms were included in calculated positions and treated as riding atoms: C-H = 0.93, 0.97 and 0.96 Å for aromatic CH, CH<sub>2</sub>, and CH<sub>3</sub> H-atoms, respectively, with  $U_{iso}(H) = k \times U_{eq}(C)$ , where k = 1.5 for CH<sub>3</sub> H-atoms, and k = 1.2 for all other H-atoms.



### Figure 1

View of title molecule with 50% probability displacement ellipsoids [Symmetry codes: (i) -x + 1/2, -y + 1/2, z (ii) y, -x + 1/2, -z + 1/2 (iii) -y + 1/2, x, -z + 1/2].



### Figure 2

Crystal packing diagram of the title compound viewed along the *c* axis.



**Figure 3** Synthesis scheme.

Tetrakis(4-tert-butylbenzyl)silane

*Crystal data* C<sub>44</sub>H<sub>60</sub>Si

 $M_r = 617.01$ 

Tetragonal,  $P4_2/n$ Hall symbol: -P 4bc Cell parameters from 25 reflections

3 standard reflections every 113 reflections

 $\theta = 7.8 - 35.3^{\circ}$ 

 $\mu = 0.72 \text{ mm}^{-1}$ 

Prism, colorless

 $h = -20 \longrightarrow 20$  $k = -20 \longrightarrow 15$ 

 $l = -7 \rightarrow 0$ 

 $0.31\times0.15\times0.12~mm$ 

 $\theta_{\rm max} = 67.4^\circ, \ \theta_{\rm min} = 3.6^\circ$ 

intensity decay: 2%

T = 295 K

a = 17.394 (2) Å c = 6.3613 (6) Å V = 1924.7 (4) Å<sup>3</sup> Z = 2 F(000) = 676  $D_x = 1.065$  Mg m<sup>-3</sup> Cu K $\alpha$  radiation,  $\lambda = 1.54184$  Å

### Data collection

Enraf–Nonius CAD-4 diffractometer non–profiled  $\omega/2\theta$  scans 5204 measured reflections 1738 independent reflections 1056 reflections with  $I > 2\sigma(I)$  $R_{\text{int}} = 0.036$ 

#### Refinement

Refinement on  $F^2$  $w = 1/[\sigma^2(F_o^2) + (0.0761P)^2 + 0.1124P]$ where  $P = (F_o^2 + 2F_c^2)/3$ Least-squares matrix: full  $R[F^2 > 2\sigma(F^2)] = 0.041$  $(\Delta/\sigma)_{\rm max} < 0.001$  $wR(F^2) = 0.135$  $\Delta \rho_{\rm max} = 0.13 \ {\rm e} \ {\rm \AA}^{-3}$  $\Delta \rho_{\rm min} = -0.11 \text{ e} \text{ Å}^{-3}$ S = 1.021738 reflections Extinction correction: SHELXL97 (Sheldrick, 106 parameters 2008), Fc<sup>\*</sup>=kFc[1+0.001xFc<sup>2</sup> $\lambda^{3}/sin(2\theta)$ ]<sup>-1/4</sup> 0 restraints Extinction coefficient: 0.0033 (6) H-atom parameters constrained

### Special details

**Geometry**. All e.s.d.'s (except the e.s.d. in the dihedral angle between two l.s. planes) are estimated using the full covariance matrix. The cell e.s.d.'s are taken into account individually in the estimation of e.s.d.'s in distances, angles and torsion angles; correlations between e.s.d.'s in cell parameters are only used when they are defined by crystal symmetry. An approximate (isotropic) treatment of cell e.s.d.'s is used for estimating e.s.d.'s involving l.s. planes.

Fractional atomic coordinates and isotropic or equivalent isotropic displacement parameters  $(Å^2)$ 

	x	У	Ζ	$U_{ m iso}^{*}/U_{ m eq}$	
Si	0.25	0.25	0.25	0.0599 (4)	
C4	0.50538 (12)	0.30509 (12)	0.4293 (4)	0.0780 (7)	
H4	0.5263	0.2856	0.5529	0.094*	
C1	0.33661 (10)	0.25820 (11)	0.0742 (4)	0.0674 (7)	
H1A	0.3507	0.2069	0.0288	0.081*	
H1B	0.3217	0.2868	-0.0502	0.081*	
C5	0.54015 (10)	0.36783 (10)	0.3360 (3)	0.0535 (5)	
C7	0.44050 (11)	0.35854 (12)	0.0714 (4)	0.0668 (6)	
H7	0.4193	0.3779	-0.0519	0.08*	
C8	0.61357 (11)	0.40291 (11)	0.4257 (4)	0.0624 (6)	
C2	0.40700 (10)	0.29575 (10)	0.1652 (4)	0.0580 (5)	
C6	0.50509 (12)	0.39375 (12)	0.1556 (4)	0.0674 (6)	
H6	0.5255	0.4365	0.0876	0.081*	
C3	0.44105 (12)	0.27021 (12)	0.3468 (4)	0.0837 (8)	
H3	0.42	0.2281	0.4163	0.1*	

С9	0.62982 (15)	0.48273 (14)	0.3328 (5)	0.0951 (9)	
H9A	0.634	0.4789	0.1827	0.143*	
H9B	0.6771	0.5023	0.3896	0.143*	
H9C	0.5885	0.517	0.3682	0.143*	
C10	0.68066 (12)	0.35026 (15)	0.3687 (5)	0.0992 (9)	
H10A	0.672	0.3001	0.4269	0.149*	
H10B	0.7275	0.3711	0.4249	0.149*	
H10C	0.6848	0.3465	0.2186	0.149*	
C11	0.60896 (17)	0.41111 (18)	0.6619 (5)	0.1047 (9)	
H11A	0.5674	0.445	0.6977	0.157*	
H11B	0.6564	0.432	0.714	0.157*	
H11C	0.6002	0.3616	0.7241	0.157*	

Atomic displacement parameters  $(Å^2)$ 

	$U^{11}$	$U^{22}$	$U^{33}$	$U^{12}$	$U^{13}$	$U^{23}$
Si	0.0473 (4)	0.0473 (4)	0.0852 (9)	0	0	0
C4	0.0612 (12)	0.0722 (13)	0.101 (2)	-0.0089 (11)	-0.0143 (12)	0.0413 (13)
C1	0.0543 (11)	0.0616 (11)	0.0863 (18)	0.0010 (9)	0.0016 (11)	0.0004 (11)
C5	0.0496 (10)	0.0501 (10)	0.0609 (12)	0.0033 (8)	0.0116 (10)	0.0070 (9)
C7	0.0658 (12)	0.0750 (13)	0.0596 (15)	-0.0063 (10)	0.0042 (10)	0.0141 (11)
C8	0.0584 (11)	0.0644 (12)	0.0645 (15)	-0.0057 (9)	0.0067 (10)	0.0059 (10)
C2	0.0477 (10)	0.0504 (10)	0.0759 (14)	0.0042 (8)	0.0086 (10)	0.0056 (10)
C6	0.0688 (12)	0.0698 (13)	0.0638 (14)	-0.0169 (10)	0.0105 (12)	0.0169 (11)
C3	0.0617 (12)	0.0677 (13)	0.122 (2)	-0.0127 (10)	-0.0093 (14)	0.0472 (14)
C9	0.0946 (17)	0.0790 (15)	0.112 (2)	-0.0315 (13)	-0.0090 (16)	0.0155 (15)
C10	0.0538 (12)	0.111 (2)	0.133 (3)	0.0025 (13)	0.0030 (14)	-0.0136 (19)
C11	0.118 (2)	0.120 (2)	0.0760 (19)	-0.0328 (17)	0.0054 (17)	-0.0061 (17)

Geometric parameters (Å, °)

Si—C1 <sup>i</sup>	1.882 (2)	C8—C11	1.512 (3)
Si—C1 <sup>ii</sup>	1.882 (2)	C8—C10	1.527 (3)
Si—C1 <sup>iii</sup>	1.882 (2)	C8—C9	1.535 (3)
Si—C1	1.882 (2)	C2—C3	1.372 (3)
C4—C3	1.377 (3)	С6—Н6	0.93
C4—C5	1.382 (3)	С3—Н3	0.93
C4—H4	0.93	С9—Н9А	0.96
C1—C2	1.504 (3)	C9—H9B	0.96
C1—H1A	0.97	С9—Н9С	0.96
C1—H1B	0.97	C10—H10A	0.96
C5—C6	1.375 (3)	C10—H10B	0.96
C5—C8	1.526 (3)	C10—H10C	0.96
C7—C2	1.374 (3)	C11—H11A	0.96
С7—С6	1.387 (3)	C11—H11B	0.96
С7—Н7	0.93	C11—H11C	0.96
C1 <sup>i</sup> —Si—C1 <sup>ii</sup>	110.68 (7)	C3—C2—C7	116.09 (19)

C1 <sup>i</sup> —Si—C1 <sup>iii</sup>	107.08 (14)	C3—C2—C1	122.34 (18)
C1 <sup>ii</sup> —Si—C1 <sup>iii</sup>	110.68 (7)	C7—C2—C1	121.6 (2)
C1 <sup>i</sup> —Si—C1	110.68 (7)	C5—C6—C7	122.44 (19)
C1 <sup>ii</sup> —Si—C1	107.08 (14)	С5—С6—Н6	118.8
C1 <sup>iii</sup> —Si—C1	110.68 (7)	С7—С6—Н6	118.8
C3—C4—C5	122.7 (2)	C2—C3—C4	121.94 (19)
C3—C4—H4	118.7	С2—С3—Н3	119
С5—С4—Н4	118.7	С4—С3—Н3	119
C2—C1—Si	117.14 (16)	С8—С9—Н9А	109.5
C2—C1—H1A	108	С8—С9—Н9В	109.5
Si—C1—H1A	108	H9A—C9—H9B	109.5
C2—C1—H1B	108	С8—С9—Н9С	109.5
Si—C1—H1B	108	H9A—C9—H9C	109.5
H1A—C1—H1B	107.3	H9B—C9—H9C	109.5
C6—C5—C4	115.05 (19)	C8—C10—H10A	109.5
C6—C5—C8	123.50 (17)	C8—C10—H10B	109.5
C4—C5—C8	121.4 (2)	H10A—C10—H10B	109.5
C2—C7—C6	121.8 (2)	C8—C10—H10C	109.5
С2—С7—Н7	119.1	H10A—C10—H10C	109.5
С6—С7—Н7	119.1	H10B—C10—H10C	109.5
C11—C8—C5	111.41 (19)	C8—C11—H11A	109.5
C11—C8—C10	109.4 (2)	C8—C11—H11B	109.5
C5—C8—C10	108.13 (17)	H11A—C11—H11B	109.5
C11—C8—C9	107.9 (2)	C8—C11—H11C	109.5
C5—C8—C9	111.83 (18)	H11A—C11—H11C	109.5
C10—C8—C9	108.09 (19)	H11B—C11—H11C	109.5

Symmetry codes: (i) -y+1/2, x, -z+1/2; (ii) -x+1/2, -y+1/2, z; (iii) y, -x+1/2, -z+1/2.